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Information Disclosure Statement By Applicant

(Use Several Sheets if Necessary)

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U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub- class
	Α					
	В					

Foreign Patent or Published Foreign Patent Application

Examiner		Document	Date	Country or		Sub-	Transla	ition
Initial	No.	No.		Patent Office	Class	class	Yes	No
	С	499109 (Patent Abstracts of Taiwan)	08/11/2002	TW	H02P	007/24	X	
	D	499109	08/11/2002	TW	H02P	007/24		X
	Ε	536064 (Patent Abstracts of Taiwan)	06/01/2003	TW	H02P	005/46	X	
	F	536064	06/01/2003	TW	H02P	005/46		X
	G	2002-058273 (Patent Abstracts of Japan)	02/22/2002	JP	H02P	5/06	X	
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	М	2001-025288 (Patent Abstracts of Japan)	01/26/2001	JP	H02P	7/06	X	
	N	2001-025288	01/26/2001	JP	H02P	7/06		X

Other Documents

Examiner				
Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication		
	0			
Examiner		Date Considered		

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.